Electron diffraction & HRTEM Image Simulation

Ecole Nord Africaine et workshop en Microscopie Electronique

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TEM diffraction/image simulation

- ► Why?
- ► How?
 - Methods.
 - Applications.

Quantitative simulation?

- Problems.
- Perfect microscopes.

Why diffraction/image simulation?

 $HR(S)TEM \implies$ to acquire knowledge on observed material (oriented in particular [uvw] directions):

- Specimen structure..
- Chemical composition.
- Functional properties.

> ...

But HR(S)TEM images depend of several adjustable microscope parameters.

For example object defocus affects strongly HRTEM images.

Structure: *Si*₃*N*₄ P 63: [001]



Images: Si₃N₄ P 63: [001], 10 nm thick, -9 nm defocus





Imaging parameters: Titan 80-300 (300 kV), C_s -0.033 mm

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*Si*₃*N*₄ P 63: [001], 10 nm thick, -3 nm defocus





Imaging parameters: Titan 80-300 (300 kV), C_s -0.033 mm

How to do diffraction/image simulation?

Formation of Electron Microscopy diffraction/images involves complex physical processes.

Approximations and models of these physical processes

are required in order to perform computer simulations. Models are based on electron scattering, diffraction, optics, ...

Needed: crystallography, optics, quantum mechanics, ... and computer programming.

TEM (very) simplified model



Modeling steps: Incident wave (PW), crystal (OP), electron-matter interaction, Fraunhofer approximation, image formation (Abbe theory), ...

Image formation modeling (HRTEM)



$|\chi > \implies$ incident wave function



Prior to perform any calculation the following items (from the electron source to the detector) must characterized and modeled:

- ► The electron beam properties.
- ► The specimen properties¹.
- How is the incident electrons beam scattered by the specimen?
- ► How does the microscope transfer the scattered electron beam?
- How do we measure the properties of the scattered electron beam (diffraction, image, hologram)?
- What are the properties of the detection system?

¹file://localhost/Applications/jemsMacOSX/html/Rb2WO9/Rb2WO9.html

- Object.
- Scattering & diffraction.
- Image formation:
 - ► HRTEM.
 - ► HRSTEM.
- Image acquisition.

Modeling the object

Evolution operator U (z, 0) defines the object properties

- 1. Amorphous material or crystalline material.
- 2. Thin or thick.
- 3. Orientation (high or low symmetry [uvw]).

You might have to transform the unit cell in order to perform dynamical calculations².



Any model is considered a periodic unit cell independent of its complexity.

²See International Tables for Crystallography (1992) Vol. 1, Chapter 5.



Figure: Carbon. Red: real part, green: imaginary part, blue: thermal diffuse scattering.

Figure: Gold. Red: real part, green: imaginary part, blue: thermal diffuse scattering.

The TDS (Thermal Diffuse Scattering) at large s (=sin(θ)) scales as $\approx Z^{1.7}$. It explains HAADF (High Angle Annular Dark Field) atomic column contrast.

Atomic form factors

Atomic form factors have been tabulated by many authors:

- 1. Doyle-Turner and Smith-Burge.
- 2. E.J. Kirkland.
- 3. Peng-Ren-Dudarev-Whelan.

4. ...

Take care ASA of heavy atoms aren't always tabulated properly.



A extremely useful ASA tabulation including phonon and core loss absorption is due to Weickenmeier-Kohl³.

³A. Weickenmeier, H. Kohl, Acta Cryst. A 47 (1991) 590.

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Crystal structure are defined by:

- 1. a, b, c, α , β , γ lattice parameters.
- 2. Space-group or symmetry operators.
- 3. Atoms positions (Symbol, x, y, z with 0 \leqq (x, y, z) \lneq 1)

 $>10^5$ crystal structures provided by data bases (ICSD, Min. Soc. Ame., Cryst. Open Database)

Useful severs:

www.minsocam.org www.crystallography.net www.cryst.ehu.es

ICSD & AMS: data bases for crystal structures





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Scattering & diffraction

Scattering: electron-matter interaction



An incident electron of wave vector \vec{k}_0 interacts with a solid of scalar potential $V(\vec{r})$. The wave vector of the scattered electron is $\vec{k}_q = \vec{k}_0 + \vec{q}$ where \vec{q} is the momentum transferred by the solid⁴.

Elastic scattering
$$\longrightarrow ||\vec{k}_q|| = ||\vec{k}_0||.$$

⁴Magnetic and spin effects are ignored.

X-Ray diffraction: Bragg law

With energy conservation and momentum transfer ($\vec{s_g} = 0$):

$$|\vec{k}_i + \vec{g}| = |\vec{k}_g|$$

$$k_i^2 + 2 \times k_i \times g \times \cos(\vec{k}_i, \vec{g}) + g^2 = k_g^2$$

$$2k_i \times \cos(\vec{k}_i, \vec{g}) = -g$$

$$2k_i \times \cos(90^\circ - \theta_B) = -g$$

$$\frac{2}{\lambda} \times \sin(\theta_B) = g = \frac{1}{d_g}$$

 \implies Bragg law:

 $2 \times d_{hkl} \times \sin(\theta_B) = \lambda$

Diffraction geometry



Center of the Ewald sphere (C) and Center of the Laue Circle (CLC), projection of C onto the zero order Laue zone. All reflections on the circle of radius χ are at exact Bragg condition.
 Notice that the Bragg angles are pretty small (of the order a few °) and that consequently the small angle approximation is quite good.

The structure factor gives the scattering *strength* of (h,k,I) planes.

$$F_{hkl} = \sum_{i=atomes} f_i(s_{hkl}) e^{(2\pi i (hx_i + ky_i + lz_i))}$$

where:

1. $f_i(s_{hkl})$ is the atomic scattering amplitude. 2. (x_i, y_i, z_i) are the fractional coordinates of atom i ($0 \le x_i < 1$). 3. $s_{hkl} = \frac{sin(\theta_B)}{\lambda} = \frac{1}{2d_{hkl}}$.

Crystal symmetries: extinction rules + kinematical diffraction

In general all reflections allowed by the Bravais lattice are visible:

Simple cubic: (hkl) no condition. 1 atom at (0, 0, 0).

$$\implies$$
 $F_{hkl} = f_i(s_{hkl})$

Body centered cubic: (hkl) : h + k + l = 2n2 atoms at (0,0,0) and $(\frac{1}{2}, \frac{1}{2}, \frac{1}{2})$.

$$\implies$$
 $F_{hkl} = f_i(s_{hkl}) \left[1 + e^{\pi i (h+k+l)} \right]$

Face centered cubic: (hkl) all even or odd. 4 atoms at (0, 0, 0), $(0, \frac{1}{2}, \frac{1}{2})$, $(\frac{1}{2}, 0, \frac{1}{2})$, $(\frac{1}{2}, \frac{1}{2}, 0)$

$$\implies F_{hkl} = f_i(s_{hkl}) \left[1 + e^{\pi i (h+k)} + e^{\pi i (h+l)} + e^{\pi i (k+l)} \right]$$



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$< q | U(z, 0) | \chi > \implies$ Fourier transform of object wavefunction

Dynamical scattering (many approaches under small angle approximation and elastic scattering).

Gratias & Portier: small angle & elastic scattering approximations



Figure: From Gratias and Portier ⁵

⁵D. Gratias and R. Portier, Acta Cryst. **A39** (1983) 576.

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All approximations are numerically equivalent, but perform best in particular cases.

We will consider only 2 approximations:

- ► The multislice approximation⁶.
- ► The Bloch-wave method⁷.

The multislice method performs best when simulating crystalline or amorphous solids of large unit cell or containing defects while the Bloch-wave method is adapted to the calculation of crystalline solids of small unit cell and in any [uvw] orientation. The Bloch-wave method has also several advantages (speed, ease of use) for simulating CBED, LACBED or PED patterns and for polarity and chirality determination.

⁶J. Cowley and A.F. Moodie, Proc. Phys. Soc. B70 (1957) 486, 497 and 505.

⁷H. A. Bethe, Ann. Phys. 87 (1928), 55.



The solid is sliced into thin sub-slices. The incident wave-function is transferred by the first slice (diffraction) and propagated to the next one. The propagation is done within the Fresnel approximation, the distance between the slices being 20 - 50 times the wavelength⁸.

⁸file://localhost/Applications/jemsMacOSX/html/PtOct/a.html

Can simulate:

- Perfects crystals.
- Defects under the periodic continuation assumption.

2 steps:

- Diffractor: transfer by a slice \Rightarrow multiplication by phase object function ($POF(\vec{\rho})$).
- ▶ Propagator: propagation between slices ⇒ convolution by the Fresnel propagator (is nowadays performed by a FFT followed by a multiplication and an inverse FFT (*FT*⁻¹, multiplication, FFT)).

⁹K. Ishizuka, Acta Cryst. A33 (1977) 740-749.

Multislice: periodic continuation¹⁰



Figure: Model (one unit cell).

Figure: Model with periodic continuation $(2 \times 2 \text{ unit cells})$.

¹⁰A.J. Skarnulis, Thesis, Arizona State University 1975.

Example multislice: Pt catalyst



A: catalyst model (9500 atoms)¹¹. B: HREM image (Jeol 400kV).

¹¹file://localhost/Applications/jemsMacOSX/html/pot3D/pot3D.html
Bloch wave method: z-independent potential

When the scattering potential is periodic, the eigenstates $|j\rangle$ of the propagating electrons are Bloch waves. The hamiltonian of the system is projected on the eigenstates $|j\rangle$ with eigenvalues γ_i ("anpassung" parameter).

$$\widehat{H} = \sum_j \gamma_j |j> < j|$$

The evolution operator is then given by (since $V = V(\vec{\rho})$):

$$\widehat{U}(z,0) = e^{-i\widehat{H}z} = \sum_{j} e^{-i\gamma_{j}z} |j\rangle \langle j|$$

The wave-function at z developed on plane waves basis |q>:

$$\begin{split} \Psi(z) &= \sum_{q} \phi_{q}(z) |q> \\ \phi_{q}(z) &= < q |\widehat{U}(z,0)| 0> = \sum_{j} e^{-i\gamma_{j}z} < q |j> < j |0> \\ c_{0}^{*j} &= < j |0> \text{ and } c_{q}^{j} = < q |j> \end{split}$$

where in usual notation c_0^{*j} and c_q^j are the Bloch-wave excitations (component of the initial state |0 > on |j >) and coefficients (component of reflection |q > on |j >) respectively.

Simulation of:

- SAED (kinematical and dynamical).
- CBED (polarity).
- LACBED (specimen thickness, symmetry).
- ► PED (Precession Electron Diffraction).

HRTEM.

Works best for small lattice parameters crystals.

CBED: ZnTe [110]





Figure: Bloch-wave 5 (Te-Zn).

Figure: Bloch-wave 7 (Te-Zn).

Figure: Bloch-wave 8 (Te-Zn).

Figure: CBED (ZnTe polarity).

SAED: Diffraction pattern & specimen thickness



In BFP diffraction pattern depends specimen thickness.

Goodness of dynamical diffraction theories?

LACBED: Si [001]



Figure: LACBED Si [001]: simulation.

Figure: LACBED Si [001]: experimental (Web site EM centre - Monash university, J. Etheridge).

Note that the experimental LACBED pattern is blurred (inelastic scattering and/or MTF of CCD camera?).

 $\frac{\text{Electron crystallography} \implies \text{precession electron diffraction (Spinning Star)}.$ Questions:

1. Are dynamical effects important?

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- 2. Can we interpret the measured intensities as:

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 - n-beams dynamical?
- 3. Best precession angle?
- 4. Maximum crystal thickness?



Figure: Structure projection CdCu₂

Figure: Dynamical SAED pattern (5 nm)

$CdCu_2[001]$: precession

Figure: CdCu₂ kinematical SAED pattern.



CdCu2 (121 reflections), thickness:10.0 [nm] AV/kV:100.00, CL/mm:3000, ZA:[0, 0, 1]=[0, 0, 0, 0, 1], FN:[0, 0, 1]=[0, 0, 0, 1]

Figure: CdCu₂ dynamical SAED pattern (5 nm)

$CdCu_2[001] - ZAP$

Figure: Kinematical.



CdCu2 (121 reflections), thickness:10.0 [nm] AV/kV:100.00, CL/mm:3000, ZA:[0, 0, 1]=[0, 0, 0, 0, 1], FN:[0, 0, 1]=[0, 0, 0, 1]

Figure: Dynamical (121 - beams).

$CdCu_2[001]$ – precession 3^o

Figure: Kinematical.

CdCu2::Precession::[u,v,w]:[0, 0, 1]::Angle / deg. :3.00

Thickness / nm : 21.0

Figure: Dynamical (121 - beams).

At first sight kinematical approximation looks sufficient (detailed values are available).

Image formation

Paraxial optics: perfect thin lens



Principal rays of paraxial optics. Reflection (plane wave) making an angle α , where $\alpha = 2\theta_B$, corresponds to spatial frequency q.



In presence of spherical aberration, the optical path length (OPL') form A_o to A'_i is smaller than OPL from A_o to A_i . The wavefront at A'_i is out-of-phase by¹²:

$$e^{-2\pi i \frac{C_s \lambda^3 (\vec{q} \cdot \vec{q})^2}{4}}$$

¹²With our plane wave choice.

Optical Path Length: underfocus



Underfocus weakens the objective lens, i.e. increases f. As a consequence the OPL from A_o to A'_i is larger:

$$e^{2\pi i \frac{\Delta f \lambda(\vec{q} \cdot \vec{q})}{2}}$$

Optical Path Length: eccentricity



On the contrary keeping f constant and moving the object by Δa decreases the OPL.

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Transfer by objective lens: < q' | T(q', q) | q >

Image forming system has 2 properties (Abbe theory):

- ► Linear.
- Space invariant.

Coherence of illumination:

- Source size (spatial coherence).
- Energy spread (temporal coherence).

HRTEM: T (q', q) : transmission cross-coefficients \implies approximation by envelope functions.

Microscope modeling: Abbe image formation theory

Objective lens is modeled as a thin lens that brings Fraunhofer diffraction pattern at finite distance (i.e. in its Back Focal Plane).



Transfer function $T(\vec{q})$

$$T(\vec{q}) = e^{\chi(\vec{q})} = \cos(\chi(\vec{q})) + i \underbrace{\sin(\chi(\vec{q}))}_{\text{Contrast transfer function}}$$

$$\chi(\vec{q}) = \pi \left[W_{20} \lambda \vec{q}.\vec{q} + W_{40} \frac{\lambda^3 (\vec{q}.\vec{q})^2}{2} + \dots \right]$$

Where:

- W_{20} : defocus (z)
- W_{40} : spherical aberration (C_s)

 $\{z, \pi (u^2 + v^2) \lambda\}$ (defocus) { $W(1,1), 2\pi(u\cos(\phi(1,1)) + v\sin(\phi(1,1)))$ } { $W(2,2), \pi\lambda((u-v)(u+v)\cos(2\phi(2,2))+2uv\sin(2\phi(2,2)))$ } $W(3,1), \frac{2}{3}\pi (u^2 + v^2) \lambda^2 (u \cos(\phi(3,1)) + v \sin(\phi(3,1)))$ $W(3,3), \frac{2}{3}\pi\lambda^{2}(u(u^{2}-3v^{2})\cos(3\phi(3,3))-v(v^{2}-3u^{2})\sin(3\phi(3,3)))\}$ $W(4,0), \frac{1}{2}\pi (u^2 + v^2)^2 \lambda^3$ (spherical aberration) $W(4,2), \frac{1}{2}\pi (u^2 + v^2) \lambda^3 ((u - v)(u + v) \cos(2\phi(4,2)) + 2uv \sin(2\phi(4,2))) \}$ $W(4,4), \frac{1}{2}\pi\lambda^{3}\left(\left(u^{4}-6v^{2}u^{2}+v^{4}\right)\cos(4\phi(4,4))+4u(u-v)v(u+v)\sin(4\phi(4,4))\right)\right\}$ $W(5,1), \frac{2}{5}\pi (u^2 + v^2)^2 \lambda^4 (u \cos(\phi(5,1)) + v \sin(\phi(5,1))) \Big\}$ $W(5,3), \frac{2}{5}\pi (u^2 + v^2) \lambda^4 (u (u^2 - 3v^2) \cos(3\phi(5,3)) - v (v^2 - 3u^2) \sin(3\phi(5,3)))$ $W(5,5), \frac{2}{5}\pi\lambda^{4} \left(u \left(u^{4} - 10v^{2}u^{2} + 5v^{4} \right) \cos(5\phi(5,5)) + v \left(5u^{4} - 10v^{2}u^{2} + v^{4} \right) \sin(5\phi(5,5)) \right) \right\}$ $W(6,0), \frac{1}{3}\pi (u^2 + v^2)^3 \lambda^5$ $W(6,2), \frac{1}{3}\pi (u^2 + v^2)^2 \lambda^5 ((u - v)(u + v) \cos(2\phi(6,2)) + 2uv \sin(2\phi(6,2)))$ $W(6,4), \frac{1}{2}\pi\lambda^5\left(\left(u^6 - 5v^2u^4 - 5v^4u^2 + v^6\right)\cos(4\phi(6,4)) + 4uv\left(u^4 - v^4\right)\sin(4\phi(6,4))\right)\right\}$ $\{W(6,6), \frac{1}{2}\pi\lambda^5((u^6-15v^2u^4+15v^4u^2-v^6)\cos(6\phi(6,6))+2uv(3u^4-10v^2u^2+3v^4)\sin(6\phi(6,6)))\}$

Contrast transfer function: $sin(\chi(\vec{q}))$



The transfer function of the objective lens in the absence of lens current and accelerating voltage fluctuations (Scherzer defocus). The (111) and (022) reflections of Si are phase shifted by $-\frac{\pi}{2} \rightarrow$ black atomic columns.

HRTEM image intensity: WPOA

In the Weak Phase Object Approximation under optimum transfer conditions the image intensity $I(\vec{x})$ is:

▶ positive *C_s* (black atomic columns)

$$I(\vec{x}) \sim 1 - 2\sigma V_p(\vec{x})$$

• negative C_s (white atomic columns)

 $I(\vec{x}) \sim \sigma V_p(\vec{x})$

Where:

 $V_p(\vec{x})$: projected potential

 $\sigma: {\rm electron}$ matter interaction constant

HRTEM image depends on specimen thickness and object defocus

Thickness series



Si [001] images map: contrast dependence of defocus & thickness



HREM map does not include the Modulation Transfer Function (MTF) of the detector.

Problems

Problems...

Object

- \rightarrow Atomic scattering amplitude below 50 kV?
- \blacktriangleright \rightarrow Potential by DFT calculation?
- ▶ ...

...

- HRTEM \rightarrow Phase of diffracted beams evolves with specimen thickness.
- HRTEM \rightarrow MTF of image acquisition system (Stobbs factor?).
- HRTEM / HRSTEM \rightarrow Electron channeling depends on atomic column content.
- HRTEM / HRSTEM \rightarrow Aberrations of optical system.
- ► HRTEM → Inelastic scattering (J.M. Cowley, E.J. Kirkland, D. van Dyck, A. Rosenaurer, K. Ishizuka, Z.L. Wang, H. Rose, H. Mueller, L. Allen, …).
- HRTEM / HRSTEM \rightarrow Drift, vibration, Johnson-Nyquist noise¹³, ...

¹³S. Uhlemann, H. Mueller, P. Hartel, J. Zach & M. Haider, Phys. Rev. Lett. **111** (2013) 046101.

HRTEM problem: amplitude and phase of diffracted beams



Note that phase of diffracted beam is $\frac{\pi}{2}$ out-of-phase with respect to transmitted beam.

HRTEM problem: CCD MTF (Gatan MSC 1K x 1K, 24 μ m)

To make quantitative comparison with experimental HRTEM images the MTF of the detector must be introduced in the simulation.

MTF

1.00



Figure: At high magnification Si (220) planes imaged with high contrast.

Figure: At low magnification Si (220) planes imaged with low contrast.

For quantitative comparison always use highest possible magnification (or include CCD MTF in simulations)!



Camera MTF & PSF

1.0



Figure: A: Si [001] simulation.

Figure: B: Si [001], simulation + CCD MTF.



Figure: A: Si [001] simulation.

Figure: B: Si [001], simulation + CCD MTF.

HRTEM / HRSTEM problem: electron channeling (ZnTe [110])



Figure: ZnTe [110] wave function intensity.

Channeling explains several features of HRTEM and STEM images (i.e. appearance / disappearance of contrast of impurities).
Does C_s and C_c correction solves all imaging problems?

Example: Cd*Cu*₂, visibility of the 3 Cu atomic columns.





HRTEM image simulation conditions

Acc. [kV]	$C_s[mm]$	$C_5[mm]$	$C_c[mm]$	$\Delta E[eV]$	Z [nm]	$\Delta z[nm]$
300	-0.008	30	0.5	0.6	-4.9	1
300	-0.008	30	0.1	0.2	-2.0	1

Dynamical scattering effects are not affected by C_s and/or C_c corrected TEM!

*CdCu*₂[001]: imaging parameters set 1



Visibility of 3 Cu atomic columns depends on specimen thickness and defocus.

*CdCu*₂[001]: imaging parameters set 2



Improving C_c and ΔE does not affect the visibility of 3 the Cu atomic columns. It depends on specimen thickness (and defocus indeed). Visibility of the 3 Cu atomic columns is always affected by dynamical scattering. Only extremely thin specimen (≤ 10 nm) will allow faithful imaging of crystal projected potential.

High Angle Annular Dark Field (HAADF): inelastically scattered electrons.

When simulation is necessary how to simulate images?

Numerous approximations:

- Simple projected + convolution with probe intensity: no channeling effect (Weak Object Approximation).
- Multislice calculation: channeling + inelastic scattering (absorption potential) + convolution with probe intensity.
- Frozen lattice (phonon) approximation: atoms of super-cell displaced out of equilibrium position, probe scanned on imaged area, intensity collected by annular detector.
- Pennycook, Nellist, Ishizuka, Shiojiri, Allen, Wang, Rosenauer, van Dyck, ...

Except the first 2 methods, simulation time expensive (luxury?). Approximations (necessity) may suffice...

HAADF: graphene



Figure: Proj. pot. approx.

Figure: Channeling calculation.



Figure: Frozen lattice 5 conf. Figure: Frozen lattice 10 conf.

HRSTEM - HRTEM comparison: graphene with add atoms



Figure: Graphene with Si in 6 C ring, Si substitutional and 2 C column.

Graphene HAADF (100 kV, 70 -150 mrad)



Figure: Frozen lattice (\sim 400 s).

Figure: Channeling (~ 2 s).

One Si shows more contrast than 2 C atoms (i $\sim Z^2$) : 14² compared to $\sim 2 \times 6^2$.

Graphene HRTEM (100 kV, $C_s - 0.033 mm$)



Figure: Weak phase object app., $C_c = 0.5mm$

Figure: Multislice, $C_s = -0.033mm$, $C_c = 0$, no thermal magnetic noise.

HRTEM does not display the strong contrast difference between one Si and two C as given by HAADF.

No doubt that image simulation necessary for quantitative work¹⁴.

- Exit wave function recovery using focal series reconstruction.
- Transport of intensity equation.

But... can also be used for teaching or planing HRTEM/HRSTEM observations.

¹⁴K. W. Urban, Science **321** (2008) 506.

HRTEM / HRSTEM problem: aberrations of optical system

Reaching 0.05 nm resolution sets very strong conditions on aberrations correction.



Figure: Aberration figure of $C_{34}(0.5\mu m)$, phase jump at $\frac{\pi}{4}$.



Figure: Optical Transfer Function.

Note that Optical Transfer Function (HRSTEM) transfers higher spatial frequencies than Ccoherent Transfer Function (HRTEM).

→ Let's look at perfect microscopes!

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Dynamical theory of elastic scattering of high energy electron

We aim to understand in details multiple elastic scattering of electrons by crystals.

- ► High energy electron (eE).
- Periodic interaction potential $V(\vec{r})$.
- Time independent flux of incident electrons.

The fundamental equation of electron elastic scattering by a potential V_v [Volt](positive inside a crystal) in the approximation of a stationary flux of electrons of a given energy e E is the Schrödinger equation ([?]):

$$\Delta \Phi(\vec{r}) + \frac{2me}{\hbar^2} [E + V_v(\vec{r})] \Phi(\vec{r}) = 0$$

With a change of notation its is written as:

$$\left[\triangle + 4\pi^2 K_i^2\right] \Phi(\vec{r}) = -4\pi^2 V_v(\vec{r}) \Phi(\vec{r})$$

Where the wavevector $|\vec{K}_i|$ of the incident electrons is given by:

$$|K_i| = \frac{\sqrt{2meE}}{h}$$

and

$$m = \gamma m_0$$

Schrödinger equation

The Laplacian $\triangle = \frac{\partial^2}{\partial x^2} + \frac{\partial^2}{\partial y^2} + \frac{\partial^2}{\partial z^2}$ is written as: $\triangle_{\rho} + \frac{\partial^2}{\partial z^2}$. As a result, $[\triangle + ...]e^{2\pi i k_z z} \Psi(\rho; z)$ is given by: $[\triangle_{\rho} + \frac{\partial^2}{\partial z^2} + ...]e^{2\pi i k_z z} \Psi(\rho; z)$. Performing the z-differentiation:

$$\frac{\partial^2}{\partial z^2} e^{2\pi i k_z z} \Psi(\rho; z) = e^{2\pi i k_z z} \left[-4\pi^2 k_z^2 + 4\pi i k_z \frac{\partial}{\partial z} + \frac{\partial^2}{\partial z^2}\right] \Psi(\rho; z)$$

Inserting the last expression and dropping the term $e^{2\pi i k_z z}$:

$$\begin{split} [\triangle_{\rho} + 4\pi^{2}(K_{i}^{2} - k_{z}^{2} + V(\rho; z)) + 4\pi\imath k_{z}\frac{\partial}{\partial z} + \frac{\partial^{2}}{\partial z^{2}}]\Psi(\rho; z) &= 0 \\ \\ \text{Since } K_{i}^{2} &= k_{z}^{2} + \chi^{2}: \\ [\triangle_{\rho} + 4\pi^{2}\chi^{2} + 4\pi^{2}V(\rho; z) + 4\pi\imath k_{z}\frac{\partial}{\partial z} + \frac{\partial^{2}}{\partial z^{2}}]\Psi(\rho; z) &= 0 \end{split}$$

Rearranging the last equation:

$$\imath \frac{\partial \Psi(\rho;z)}{\partial z} = -\frac{1}{4\pi k_z} [\triangle_{\rho} + 4\pi^2 \chi^2 + 4\pi^2 V(\rho;z) + \frac{\partial^2}{\partial z^2}] \Psi(\rho;z)$$

$$i\frac{\partial\Psi(\rho;z)}{\partial z} = -\frac{1}{4\pi k_z} [\triangle_{\rho} + 4\pi^2\chi^2 + 4\pi^2 V(\rho;z) + \frac{\partial^2}{\partial z^2}]\Psi(\rho;z)$$

The term $\left|\frac{\partial^2 \Psi(\rho;z)}{\partial z^2}\right|$ being much smaller than $\left|k_z \frac{\partial \Psi(\rho;z)}{\partial z}\right|$ we drop it (this is equivalent to neglect backscattering).

Fundamental equation of elastic scattering of high energy mono-kinetic electrons with a potential within the approximation of small angle scattering:

$$\iota \frac{\partial}{\partial z} \Psi(\rho; z) = -\frac{1}{4\pi k_z} [\triangle_\rho + 4\pi^2 \chi^2 + 4\pi^2 V(\rho; z)] \Psi(\rho; z)$$

Time dependent Schrödinger equation \implies solution by many methods of quantum mechanics!

Remarks

- ► The approximations of the fundamental equation are equivalent to assume that the scattering potential is small compared to the accelerating potential and that k_z varies only slightly with z. It is in fact a quite good approximation, since the mean crystal potential is of the order of 10 20 V.
- Electron backscattering is neglected, the electron are moving forwards.
- ► The fundamental equation is actually equivalent to a 2-dimensional Schrödinger equation (ρ = {x, y}) where z plays the role of time. The system evolution is causal, from the past to the future.

Fundamental equation in Hamiltonian form:

$$\imath \frac{\partial}{\partial z} \Psi = H \ \psi$$

where:

$$H = -\frac{1}{4\pi k_z} [\triangle_{\rho} + 4\pi^2 \chi^2 + 4\pi^2 V(\rho; z)] = H_o + \frac{4\pi^2 V(\rho; z)}{4\pi k_z}$$

A fundamental postulate of quantum mechanics ([?, ?]) says that the evolution operator obeys the equation:

$$u \frac{\partial}{\partial z} U(z,0) = H(\rho;z) \ U(z,0)$$

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Causal evolution operator

U(z, 0): unitary operator (the norm of $|\Psi\rangle$ is conserved), in general not directly integrable \implies approximations.

U(z, 0) can be directly integrated only when $H(\rho; z)$ and $\frac{\partial}{\partial z}H(\rho; z)$ commute. In that case the general solution is [?]:

$$U(z,0) = e^{-i \int_0^z H(\tau) d\tau}$$

 $H(\rho; z)$ and $\frac{\partial}{\partial z}H(\rho; z)$ commute when:

- $V(\rho; z)$ does not depend on z, i.e. $V(\rho; z) = V(\rho)$ (perfect crystal).
- $V(\rho; z)$ can be neglected (free space propagation).
- $H(\rho; z)$ is approximated by it potential term (phase object).

Three approximations are available in jems:

- Multislice method.
- Bloch wave method.
- Howie-Whelan column approximation.

Future of HRTEM simulation with the C_s and C_c corrections?

Example: Cd*Cu*₂, visibility of the 3 Cu atomic columns.





HRTEM image simulation conditions

Acc. [kV]	$C_s[mm]$	$C_5[mm]$	$C_c[mm]$	$\Delta E[eV]$	Z [nm]	$\Delta z[nm]$
300	-0.008	30	0.5	0.6	-4.9	1
300	-0.008	30	0.1	0.2	-2.0	1

Dynamical scattering effects are not affected by C_s and/or C_c corrected TEM!



Visibility of 3 Cu atomic columns depends on specimen thickness and defocus.

*CdCu*₂[001]: imaging parameters set 2



Improving C_c and ΔE does not affect the visibility of 3 the Cu atomic columns depends on specimen thickness and defocus.

Visibility of the 3 Cu atomic columns is affected dynamical scattering (1 MeV C_s and C_c TEM).

High Angle Annular Dark Field (HAADF): inelastically scattered electrons. How to simulate images?

Various approximations:

- ► Simple projected + convolution with probe intensity: no channeling effect (WPOA).
- Multislice calculation: channeling + inelastic scattering (absorption potential) + convolution with probe intensity.
- Frozen phonons approximation: atoms of super-cell displaced out of equilibrium position¹⁵, probe scanned on imaged area, intensity collected by annular detector.
- Ishizuka: ...
- Shiojiri:...
- ▶

Except the first 2 methods, simulation time expensive. Approximations may suffice...

¹⁵file://localhost/Applications/jemsMacOSX/html/graphene/ap.html

HAADF: graphene



by 2 fold astigmatism.

Figure: Probe affected by 3 fold astigmatism.

Figure: Probe affected by coma.

Figure: Corrected probe (best defocus).



Figure: HAADF projected potential approximation. Figure: HAADF multislice calculation (simple). Figure: Frozen phonons 5 configurations.

Figure: Frozen phonons 10 configurations.

Thanks you for attention!

My gratitude to:

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